



US 20020108518A1

(19) **United States**

(12) **Patent Application Publication** (10) Pub. No.: **US 2002/0108518 A1**  
**Verschuere et al.** (43) Pub. Date: **Aug. 15, 2002**

(54) **METHOD OF LITHOGRAPHIC PRINTING  
WITH A REUSABLE SUBSTRATE**

**Related U.S. Application Data**

(60) Provisional application No. 60/259,483, filed on Jan. 3, 2001.

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(30) **Foreign Application Priority Data**

Dec. 7, 2000 (EP) ..... 00204376.8

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**Publication Classification**

(51) Int. Cl.<sup>7</sup> ..... **B41F 35/00; B41L 41/00;  
B41F 1/18**

(52) U.S. Cl. .... **101/450.1; 101/424**

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(57) **ABSTRACT**

(21) Appl. No.: **10/016,960**

A method for removing ink-accepting areas of a lithographic printing master is disclosed which enables to recycle the lithographic substrate of the printing master. The method comprises after a cleaning step a treatment of the recycled substrate with an aqueous solution having a pH<7.

(22) Filed: **Dec. 7, 2001**